

FEB 07 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Yuanning Chen, et al.

Art Unit: 2813

Serial No.: 10/719,279

Examiner: Jack S.J. Chen

Filed: 11/21/03

Docket: TI-35022.2

For: Use of Hafnium Silicon Oxynitride as the Cap Layer of the Sidewall Spacer

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

CERTIFICATION OF FACSIMILE TRANSMISSION  
I hereby certify that the above correspondence is being  
transmitted by facsimile to the U.S. Patent and Trademark  
Office at 703-872-9306 on the date shown below.

Karen Vertz 2-7-05  
Karen Vertz Date

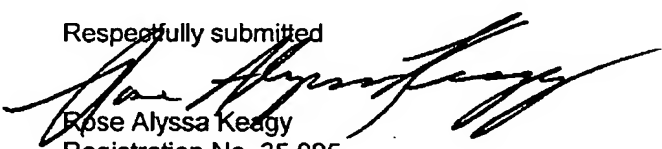
EXTENSION OF TIME

Pursuant to 37 CFR 1.136(a), Applicants respectfully petition the Commissioner for an extension of the shortened statutory period for response in the above-identified Application. The fee for this extension is indicated below:

- ☒ First Month (\$120)  
☐ Second Month (\$450)  
☐ Third Month (\$1,020)  
☐ Fourth Month (\$1,590)  
☐ Fifth Month (\$2,160)

Please charge the fee to deposit account No. 20-0668 of Texas Instruments Incorporated. The Commissioner is hereby authorized to charge any fees which may be required, or credit any overpayment to Account No. 20-0668. An original and two copies of this sheet are enclosed

Respectfully submitted

  
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